
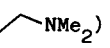
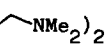



Table 1. Reaction of Grignard reagents or *n*-butyllithium with vinylsilanes.

silyl group in vinylsilane		<i>i</i> -PrMgBr Et ₂ O/rfx/15-20 h ^a	<i>n</i> -BuMgBr Et ₂ O/rfx/15 h ^a	<i>n</i> -BuLi THF/hexane/0°C/1 h ^a
-SiMe ₃	1	No RXN	No RXN	[Addn] ^b
-SiMe ₂ (OEt)	2	[Addn] ^c	[Addn] and Substn ^{c,d,e}	Substn
-SiMe ₂ (O— )	3	[Addn] ^f	No RXN ^e	[Addn] ^g
-SiPh ₂ (OEt)	4	[Addn] ^h	No RXN	---
-SiMe(OEt) ₂	5	[Addn] ^{c,h}	Substn ⁱ	---
-SiMe(OPr- <i>i</i>) ₂	6	[Addn] ⁱ	No RXN	Substn ^k
-Si(OEt) ₃	7	[Addn] and Substn ^c	Substn	Substn
-SiMe ₂ (O— )	8	[Addn] ^{l,m}	Substn ^l	---
-SiMe(O— ) ₂	9	Substn ^{i,l}	---	---
-SiMe(NEt ₂) ₂	10	No RXN	No RXN	[Addn] ⁿ
-SiMe(NMe— ) ₂	11	[Addn] ^o	---	[Addn] ^o

^a R-m : vinylsilane = 2 : 1. Yields were determined by GLC after hydrolysis (NH₄Cl solution, unless otherwise noted). ^b See ref. 4. ^c See ref. 6. ^d We have observed no reaction, as opposed to the result reported by Buell et al. (ref. 6). ^e Substitution was observed in THF. ^f Refluxed for 4 days, 40%. ^g 52% yield. ^h Quantitative yield. ⁱ Only mono-substitution product was formed. ^j Refluxed for 40 h, 72% yield. ^k Mono-substitution product was formed in 57% yield. ^l At room temperature for 15 h. ^m White precipitates were formed, 77% yield. ⁿ 80% yield. ^o Yields were 27 and 54% respectively, after coupling with allyl bromide followed by oxidation (see the subsequent paper).

2-dimethylaminoethoxy group not only activates the addition of the Grignard reagent to the vinyl group (8 vs. 2), but also facilitates the substitution at silicon (9 vs. 5), possibly due to the chelation effect. A similar effect may be noted in the aminosilane series 10 and 11: no reaction occurred with diethylaminosilane, while the addition takes place with 2-(dimethylamino)ethamino-silane.

The main purpose of the present study was to attain the addition of *n*-alkyl Grignard reagents to silafunctional vinylsilanes, but, unfortunately, substitution predominated with ethoxysilanes 5 and 7 and dimethylaminoethoxysilane 8 or no reaction occurred with sterically hindered vinylsilanes 3, 4, and 6 and with aminosilane 10. Instead, *n*-butyllithium gave adducts with (*t*-butoxy)vinylsilane 3 and (diamino)vinylsilanes 10 and 11. Of particular interest is the last result obtained with diethylaminosilanes, since Speier et al.⁸ observed only polymerization upon treatment of (dimethylamino)vinylsilanes with *n*-butyllithium. The

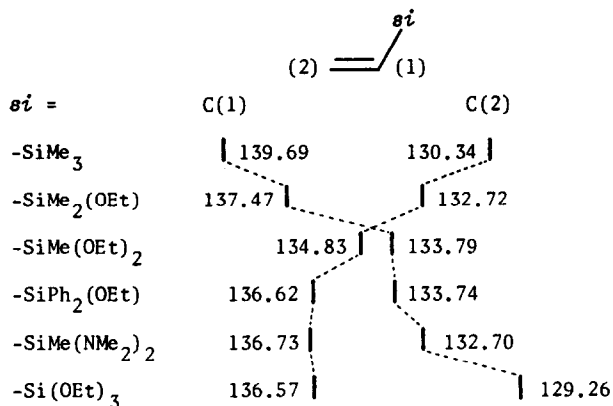


Figure 1. ¹³C NMR chemical shifts (down-field from TMS) of some pertinent vinylsilanes (ref. 11a).

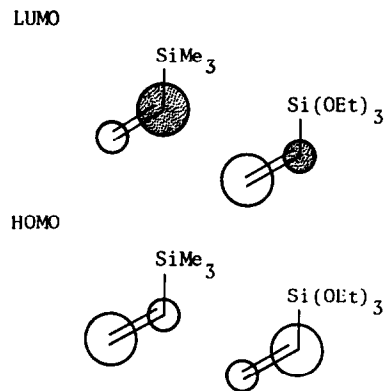


Figure 2. A schematic representation of p coefficients of π -HOMO and π^* -LUMO of vinyl-SiMe₃ and vinyl-Si(OEt)₃.

present result, therefore, provides the first successful case for the formation of the 1 : 1 adduct of vinyl(amino)silane with *n*-butyllithium. In connection with this we have also observed a similar addition reaction with *sec*- and *tert*-butyllithium.¹⁰

While reactions and further transformations of these adducts, α -silyl carbanion species, will be reported in the subsequent paper,¹⁰ the mechanism of the addition reaction will be discussed in this paper.

The addition reaction may proceed through the interaction of the nucleophile HOMO with the electrophilic vinyl group LUMO. The ¹³C NMR data of a variety of vinylsilanes which have been recently reported¹¹ clearly demonstrate that the successive displacement of the methyl group on silicon by an alkoxy group results in the steady upfield shift of the C(1) chemical shift, and conversely in the down-field shift of the C(2), as shown by the schematic representation in Fig. 1. The differences between ¹³C chemical shifts of the sp² carbon atoms in ethylenic compounds can be used as an approximation of the differences between the relative magnitudes of the two sp² carbon atom p coefficients of the π -HOMO and π^* -LUMO.¹² As shown in Fig. 2, in vinyltrimethylsilane the largest coefficient is on the C(2) in the π -HOMO and on the C(1) in the π^* -LUMO. Conversely, in dialkoxy- and trialkoxy-vinylsilanes, the largest coefficient is on the C(2) in the π^* -LUMO and on the C(1) in the π -HOMO. The interaction between the carbanion HOMO with the π^* -LUMO on the C(2) becomes much more favorable in (alkoxy)vinylsilanes in comparison with trimethylvinylsilane, resulting in the facilitation of the addition reaction. It can be also expected that a possible complexation of the electrophilic part, e.g., Mg²⁺, with the alkoxy oxygen atom¹³ should make the π^* -LUMO lobe on the C(2) larger and consequently make the addition more favorable. It should be noted here that the argument is similar to that devoted to the Diels-Alder dienophile¹⁴ for which the Lewis acid exhibits an activation and selectivity-improvement effect. The reactivities of vinyl(alkoxy)silanes are thus parallel with those of α,β -enones.¹⁵

An energy-matching is another important factor. Since the energy levels of both of the π -HOMO and π^* -LUMO are expected to be lower in (alkoxy)vinylsilane than in trimethylvinyl-

silane,^{11b} the energy factor is also more favorable to the former. The *n*-butyl Grignard reagent cannot add to those vinylsilanes which react with the isopropyl Grignard reagent, because the former is more stable than the latter.

n-Butyllithium may attack inherently the silicon center and therefore its addition is restricted to vinyl-silanes which contain a trimethylsilyl, sterically hindered alkoxysilyl, or aminosilyl group.¹⁶

REFERENCES AND NOTES

- (1) Silafunctional Compounds in Organic Synthesis. 22. For part 21 see: K. Tamao, M. Kumada, and K. Maeda, *Tetrahedron Lett.*, in press.
- (2) (a) D. J. Peterson, *J. Org. Chem.*, **33**, 780 (1968). (b) T. H. Chan and E. Chang, *ibid.*, **39**, 3264 (1974). (c) D. J. Ager, *Chem. Soc. Rev.*, 493 (1983).
- (3) T. Hayashi, M. Konishi, H. Ito, and M. Kumada, *J. Am. Chem. Soc.*, **104**, 4962 (1982).
- (4) E. Colvin, "Silicon in Organic Synthesis", Butterworths, London, 1981, pp. 21-29.
- (5) (a) H. A. Firgo and W. P. Weber, *Organometallics*, **1**, 649 (1982). (b) D. J. Ager, *Tetrahedron Lett.*, **22**, 587 (1981). For previous works, see references cited therein and in ref. 4.
- (6) G. R. Buell, R. Corriu, C. Guerin, and L. Spialter, *J. Am. Chem. Soc.*, **92**, 7424 (1970).
- (7) For heteroconjugate addition to silicon-substituted vinylsulfones see: M. Isobe, M. Kitamura, and T. Goto, *Chem. Lett.*, 331 (1980); 457 (1981).
- (8) M. R. Stober, K. W. Michael, and J. L. Speier, *J. Org. Chem.*, **32**, 2740 (1967).
- (9) Addition of *t*-BuLi to vinylchlorosilanes has been studied as a possible route to a silicon-carbon double bond: P. R. Jones, T. F. O. Lin, and R. A. Pierce, *J. Am. Chem. Soc.*, **102**, 4970 (1980).
- (10) K. Tamao, T. Iwahara, R. Kanatani, and M. Kumada, *Tetrahedron Lett.*, subsequent paper.
- (11) (a) P. E. Ratika and L. S. Worsham, *J. Organomet. Chem.*, **139**, 135 (1977). (b) V. P. Yuriev, A. A. Panasenko, V. I. Khvostenko, L. M. Khalilov, Ya. B. Yasman, M. M. Timoshenko, Yu. V. Chizhov, B. G. Zykov, I. I. Furlei, and S. R. Rafikov, *ibid.*, **166**, 169 (1979).
- (12) E.g., G. J. Martin, M. L. Martin, and S. Odier, *Org. Magn. Res.*, **7**, 2 (1975).
- (13) R. J. P. Corriu and C. Guerin, *J. Organomet. Chem.*, **198**, 231 (1980).
- (14) I. Fleming, "Frontier Orbitals and Organic Chemical Reactions", John-Wiley, London, 1976, pp. 161-165, and references cited therein.
- (15) It should be noted that an alkoxysilyl group may be regarded as a "ketal" of an imaginary "silacarbonyl" group >Si=O .
- (16) We thank Shin-etsu Chemical Industrial Co., Ltd. for support of this work and for a gift of chlorovinylsilanes. We acknowledge also Professor I. Morishima, Kyoto University, for valuable discussions concerning the theoretical treatment.

(Received in Japan 28 December 1983)